

**AMENDMENTS TO THE CLAIMS:**

Please cancel claims 22 and 26, amend claim 7, and add new claims 33-36, as indicated below.

7. (Amended) A sputter target consisting essentially of 0.001 to 30 at% of at least one first element selected from the group consisting of Y, Sc, La, Ce, Nd, Sm, Gd, Tb, Dy and Er, at least one second element selected from the group consisting of 0.01 at ppm to 3 at% of C with respect to the amount of the first element, 0.01 at ppm to 7.5 at% of O with respect to the amount of the first element, 0.01 at ppm to 7.5 at% of N with respect to the amount of the first element, and 0.01 at ppm to 7.5 at% of H with respect to the amount of the first element, and the balance of Al.

Cancel claim 22.

Cancel claim 26.

33. (New) The sputter target according to claim 7, wherein the sputter target contains N in a range of 910 at ppm or below with respect to the amount of the first element.

34. (New) The sputter target according to claim 7, wherein the sputter target contains N in a range of 420 at ppm or below with respect to the amount of the first element.

35. (New) The sputter target according to claim 7, wherein the sputter target contains N in a range of 150 at ppm or below with respect to the amount of the first element.

36. (New) The sputter target according to claim 7, wherein the sputter target contains N in a range of 70 at ppm or below with respect to the amount of the first element.